## Electrodeposition of neodymium and dysprosium from organic electrolytes

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Electronic Supplementary Information (ESI)



**Figure S1.** UV-Vis absorption spectra of 0.1 mol  $L^{-1}$  Nd(Tf<sub>2</sub>N)<sub>3</sub>, and 4 molar equivalents of TBABH<sub>4</sub> (top), NaBH<sub>4</sub> (middle), and LiBH<sub>4</sub> (bottom) in DME..



**Figure S2.** Solutions of 0.1 mol  $L^{-1}$  Dy(Tf<sub>2</sub>N)<sub>3</sub> and, from left to right 0, 1, 2, 3, 4 molar equivalents of TBABH<sub>4</sub> in DME.



**Figure S3.** UV-Vis absorption spectrum of 0.1 mol  $L^{-1}$  Nd<sub>2</sub>Cl<sub>6</sub>(DME)<sub>4</sub>, and 4 molar equivalents of LiBH<sub>4</sub> in MeTHF.



**Figure S4.** (a) CVs (first cycle) of 0.1 mol L<sup>-1</sup> NaTf<sub>2</sub>N + 4 molar equivalents of NaBH<sub>4</sub> (black curve), and 0.1 M Li(Tf<sub>2</sub>N) + 4 molar equivalents of LiBH<sub>4</sub> (red curve) in DME. (b) CVs of 0.1 mol L<sup>-1</sup> Nd(Tf<sub>2</sub>N)<sub>3</sub> + 4 molar equivalents of NaTf<sub>2</sub>N (black curve), and 4 molar equivalents of LiTf<sub>2</sub>N (red curve). The working and counter electrodes were pieces of platinum-coated silicon wafers with a surface area of 0.003 dm<sup>2</sup> and 0.01 dm<sup>2</sup>, respectively. The reference electrode was Fc<sup>+</sup>/Fc (0.005 mol L<sup>-1</sup> each) dissolved in [BMP][Tf<sub>2</sub>N]. The scan rate was 10 mV s<sup>-1</sup>.



**Figure S5.** CVs (first cycle) of 0.1 mol L<sup>-1</sup> Nd(Tf<sub>2</sub>N)<sub>3</sub> + 0 to 4 molar equivalents of (a) NaBH<sub>4</sub>, and (b) LiBH<sub>4</sub>, recorded at a scan rate of 10 mV s<sup>-1</sup>. The working and counter electrodes were pieces of platinum-coated silicon wafers with a surface area of 0.003 dm<sup>2</sup> and 0.01 dm<sup>2</sup>, respectively. The reference electrode was Fc<sup>+</sup>/Fc (0.005 mol L<sup>-1</sup> each) dissolved in [BMP][Tf<sub>2</sub>N].



**Figure S6.** CVs (first cycle) of 0.1 mol L<sup>-1</sup> Dy(Tf<sub>2</sub>N)<sub>3</sub> + 4 molar equivalents of (a) NaBH<sub>4</sub>, (b) LiBH<sub>4</sub>, and (c) TBABH<sub>4</sub> recorded at varying scan rate. The working and counter electrodes were pieces of platinum-coated silicon wafers with a surface area of 0.003 dm<sup>2</sup> and 0.01 dm<sup>2</sup>, respectively. The reference electrode was  $Fc^+/Fc$  (0.005 mol L<sup>-1</sup> each) dissolved in [BMP][Tf<sub>2</sub>N].



**Figure S7.** (a) Scanning electron micrograph of a deposit prepared at a constant potential of -3.1 V vs. Fc<sup>+</sup>/Fc in a stirred solution of 0.1 mol L<sup>-1</sup> Nd(Tf<sub>2</sub>N)<sub>3</sub> + 4 molar equivalents of NaBH<sub>4</sub> in DME at X500 magnification. (c) EDX spectrum of the deposit in the energy range 0–12 keV, recorded at an acceleration voltage of 20 kV with assignment of the major lines.



**Figure S8.** (a) Scanning electron micrograph of a deposit prepared at a constant potential of -3.1 V vs. Fc<sup>+</sup>/Fc in a stirred solution of 0.1 mol L<sup>-1</sup> Nd(Tf<sub>2</sub>N)<sub>3</sub> + 4 molar equivalents of LiBH<sub>4</sub> in DME at X500 magnification. (c) EDX spectrum of the deposit in the energy range 0–12 keV, recorded at an acceleration voltage of 20 kV with assignment of the major lines.



**Figure S9.** EDX spectra in the energy range 0–1.2 keV of neodymium deposits prepared in  $0.1 \text{ mol } L^{-1} \text{ Nd}(\text{Tf}_2\text{N})_3 + 4 \text{ molar equivalents of NaBH4, LiBH4, or TBABH4, recorded at an acceleration voltage of 20 kV. The dashed and dotted lined indicate the characteristic X-ray lines of neodymium (M<math>\alpha$  = 0.98 keV) and sodium (K $\alpha$  = 1.04 keV), respectively.



**Figure S10.** Curve-fitted C 1s XPS spectra (surface) from Nd (a) and Dy (b) deposits with a thickness of approx. 1  $\mu$ m, obtained from potentiostatic deposition in Nd(Tf<sub>2</sub>N)<sub>3</sub> or Dy(Tf<sub>2</sub>N)<sub>3</sub> + TBABH<sub>4</sub> electrolytes at -3.4 V *vs.* Fc<sup>+</sup>/Fc. The C 1s peak was shifted to 285.2 eV (mainly C–H bonds) for calibration of the spectra.



Figure S11. Curve-fitted Nd  $3d_{3/2}$  XPS spectra (surface) from deposits with a thickness of approx. 1 µm, obtained from potentiostatic deposition in Nd(Tf<sub>2</sub>N)<sub>3</sub> + TBABH<sub>4</sub> electrolytes at -3.4 V vs. Fc<sup>+</sup>/Fc.



**Figure S12.** XPS survey scans in the range 60–700 eV, of Nd (a) and Dy (b) deposits with a thickness of approx. 1  $\mu$ m, obtained from potentiostatic deposition in Nd(Tf<sub>2</sub>N)<sub>3</sub> or Dy(Tf<sub>2</sub>N)<sub>3</sub> + TBABH<sub>4</sub> electrolytes at -3.4 V *vs.* Fc<sup>+</sup>/Fc.



**Figure S13.** Curve-fitted O 1s XPS spectra (surface) from Nd (a) and Dy (b) deposits with a thickness of approx. 1  $\mu$ m, obtained from potentiostatic deposition in Nd(Tf<sub>2</sub>N)<sub>3</sub> or Dy(Tf<sub>2</sub>N)<sub>3</sub> + TBABH<sub>4</sub> electrolytes at -3.4 V *vs.* Fc<sup>+</sup>/Fc.